

b1 Cont a transparent first metal layer and a transparent second metal layer on the gate insulator.

b2 45. (Amended) The device of claim 44, wherein the transparent first metal layer is connected to the drain electrodes.

b3 56. (Amended) A method of forming an in-plane switching liquid crystal display device, comprising:
forming first and second substrates;
forming a plurality of gate and data bus lines on the first substrate, the gate lines being crossed with the data bus lines;
forming a common line in parallel to any one of the gate lines and the data bus lines on the first substrate;
forming a gate insulator on the first substrate; and
a transparent first metal layer and a transparent second metal layer on the gate insulator.

b4 59. (Amended) The method of claim 58, wherein the transparent first metal layer is connected to the drain electrodes.

REMARKS

At the outset, the Examiner is thanked for the thorough review and consideration of the subject application. The Office Action of May 24, 2002 has been received and contents carefully reviewed.